

PATENT

Case Docket No. MICRON.129DV1C1

Date: August 3, 2004



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

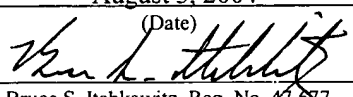
Applicant : Ronald A. Weimer
Appl. No. : 10/758,518
Filed : January 15, 2004
For : METHOD OF FABRICATING
AN INTEGRATED CIRCUIT
WITH A DIELECTRIC LAYER
EXPOSED TO A HYDROGEN-
BEARING NITROGEN SOURCE
Group Art Unit : 2824
Class/Sub-Class : 257/321000
Examiner : Douglas M. Menz

Certificate of Mailing

I hereby certify that this correspondence and all marked attachments are being deposited with the United States Postal Service as first class mail in an envelope addressed to: Mail Stop Issue Fee, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on

August 3, 2004

(Date)


Bruce S. Itchkawitz, Reg. No. 47,677

TRANSMITTAL LETTER

MAIL STOP ISSUE FEE
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing is the Issue Fee for the above-identified application, together with:

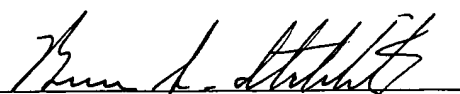
- (X) Form PTOL-85.
- (X) "Comments on Examiner's Statement of Reasons for Allowance" in two (2) pages.
- (X) A check in the amount of \$1,645.00 to cover the issue fee, publication fee, and advanced order of copies.
- (X) A return prepaid postcard.

The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment, to Account No. 11-1410.

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Date: August 3, 2004



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MICRON.129DV1C1

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Applicant : Ronald A. Weimer

Group Art Unit 2824

Appl. No. : 10/758,518

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For : METHOD OF FABRICATING AN
INTEGRATED CIRCUIT WITH A
DIELECTRIC LAYER EXPOSED
TO A HYDROGEN-BEARING
NITROGEN SOURCE

Examiner : Douglas M. Menz

COMMENTS ON EXAMINER'S STATEMENT OF REASONS FOR ALLOWANCE

United States Patent and Trademark Office
P.O. Box 2327
Arlington, VA 22202

Dear Sir:

Applicant respectfully disagrees with the Examiner's Statement of Reasons for Allowance to the extent that the limitations recited by the Examiner are not present in all of the claims.


To the extent that there is any implication that the patentability of the claims rests on the recitation of a single feature, Applicant respectfully disagrees with the Examiner's Statement because it is the combination of features that makes the claims patentable. Accordingly, Applicant submits that the claims of the present application are allowable because each of the claims recites a combination of features that are not taught or suggested by the prior art.

Appl. No. : 10/758,518
Filed : January 15, 2004

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 8/3/04

By: 

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